

This listing of claims will replace all prior versions of claims in the application.

Claim 1. (currently amended) A coated substrate comprising:

- a) an organic underlayer composition coating layer on a substrate, the underlayer composition comprising (i) a first resin that comprises phenol groups and (ii) a second resin that is distinct from the first resin and comprises one or more anthracene groups;
- b) a ~~positive-acting~~ photoresist composition coating layer over the underlayer composition, the photoresist comprising one or more resins that comprise Si groups, phenolic groups and photoacid-labile groups.

Claims 2-21. (cancelled)

Claim 22. (currently amended) A method for forming a photoresist relief image comprising:

- a) applying an organic underlayer composition coating layer on a substrate, the underlayer composition comprising (i) a first resin that comprises phenol groups and (ii) a second resin that is distinct from the first resin and comprises one or more anthracene groups;
- b) applying a ~~positive-acting~~ photoresist composition coating layer over the underlayer composition, the photoresist composition comprising a photoactive component and one or more resins that comprise Si groups, phenolic groups and photoacid-labile groups; and
- c) exposing the photoresist layer to radiation having a wavelength of about 248 nm.

Claims 23-59. (cancelled)

Claim 60. (new) The substrate of claim 1 wherein the organic underlayer composition further comprises a crosslinker component.

Claim 61. (new) The substrate of claim 60 wherein the crosslinker component comprises an amine compound.

Claim 62. (new) The substrate of claim 60 wherein the crosslinker component comprises a benzoquanamine compound.

Claim 63. (new) The substrate of claim 60 wherein the crosslinker component comprises a melamine compound.

Claim 64. (new) The substrate of claim 1 wherein the organic underlayer composition further comprises an acid or acid generator compound.

Claim 65. (new) The substrate of claim 1 wherein the second resin of the organic underlayer composition is an acrylate resin.

Claim 66. (new) The method of claim 22 wherein the organic underlayer composition further comprises a crosslinker component.

Claim 67. (new) The method of claim 66 wherein the crosslinker component comprises an amine compound.

Claim 68. (new) The method of claim 66 wherein the crosslinker component comprises a benzoquanamine compound.

Claim 69. (new) The method of claim 66 wherein the crosslinker component comprises a melamine compound.

Claim 70. (new) The method of claim 22 wherein the organic underlayer composition further comprises an acid or acid generator compound.

Claim 71. (new) The method of claim 22 wherein the second resin of the organic underlayer composition is an acrylate resin.